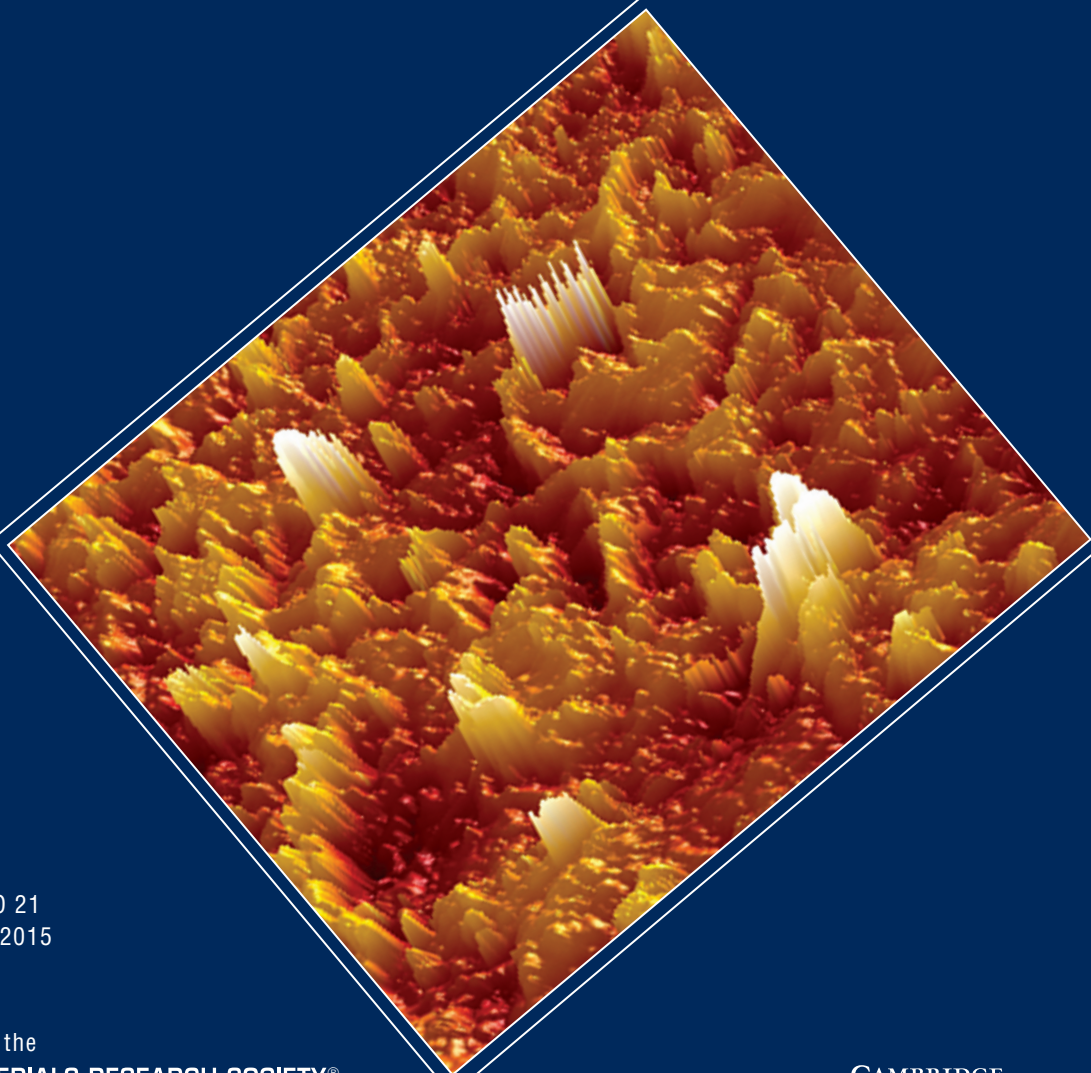


Celebrating
30 YEARS

 **Journal of
MATERIALS RESEARCH**



VOLUME 30 • NO 21
NOVEMBER 13, 2015

A publication of the

MRS MATERIALS RESEARCH SOCIETY®
Advancing materials. Improving the quality of life.

CAMBRIDGE
UNIVERSITY PRESS

Journal of MATERIALS RESEARCH

JOURNAL OF MATERIALS RESEARCH (JMR) is an interdisciplinary journal serving the materials research community through publication of original research articles and invited reviews encompassing the synthesis, processing, characterization, properties, and theoretical description of materials.

JMR publishes new research that demonstrates a significant impact or advance of scientific understanding of interest to the materials research community. Engineering studies and applications to commercial products are beyond the scope of *JMR* and should be submitted elsewhere. Manuscripts that report data without giving an analysis, interpretation, or discussion are only acceptable if the data are sufficiently important that publication is expected to lead to significant new studies or advancements in science or technology.

Manuscripts must be submitted to the *Journal of Materials Research* electronically via ScholarOne manuscripts, at the following website address: <http://mc.manuscriptcentral.com/jmr>. Electronic submission expedites the review process and also allows authors to track the status of their manuscripts at any time. Complete instructions are available on the ScholarOne site and authors will be prompted to provide all necessary information.

Manuscripts must be prepared in English, using a word processing program, formatted to fit 8½ x 11 in. paper, and saved as .doc, .pdf, .rtf, or .ps files. Separate graphics files (.eps and .tif) must be uploaded for each figure. Authors may also upload .xls or .ppt supplemental files as part of the manuscript submission process. All of these files will be converted to .pdf format. Detailed instructions are available on the submission web site. During submission, authors must enter all coauthor names and e-mail addresses. Manuscripts will not be considered for peer review until this information is provided. Authors must also enter manuscript keywords using the *JMR* keyword list (located on the submission web site). Authors who are not fluent in English must have their manuscript edited for correct English grammar and sentence structure before submission.

Authors are expected to follow the conventional writing, notation, and illustration style prescribed in *Scientific Style and Format: the CSE Manual for Authors, Editors and Publishers, 7th edition, 2006*. Authors should also study the form and style of printed material in this journal. SI units should be used. Authors should use an identical format for their names in all publications to facilitate use of citations and author indexes.

Manuscripts are accepted with the understanding that they represent original research, except for review articles, and that they have not been copyrighted, published, or submitted for publication elsewhere. Authors submitting manuscripts to *JMR* who have related material under consideration or in press elsewhere should send a copy of the related material to *JMR* at the time of submission. While their manuscripts are under consideration at *JMR*, authors must disclose any such related material. To expedite the review process, authors may provide names and contact information for up to four possible reviewers.

Articles are original research reports that include complete, detailed, self-contained descriptions of research efforts. All articles must contain an abstract and section headings.

Commentaries and Reviews: *Journal of Materials Research* occasionally publishes commentaries on topics of current interest or reviews of the literature in a given area. If an author proposes a review, the title, abstract, and a brief outline should be submitted to the Editorial Office via e-mail for prior consultation on the appropriateness of the topic.

Color policy: It is not necessary for authors to indicate that a figure should be displayed in color online. *JMR* will assume that any author who submits figures in color wants and agrees to their being produced in color online. Figures may be printed in color at the author's request for an additional charge. Color figures must be submitted before the paper is accepted for publication, and cannot be received later in the process. Authors cannot submit two versions of the same figure, one for color and one for black and white; only one version can be submitted. Authors need to carefully consider the following when submitting figures in color that will

be published in color online only: 1) The colors chosen must reproduce effectively and the colors should be distinguishable when printed in black and white; 2) The descriptions of figures in text and captions must be sufficiently clear for both online and print copy. When submitting figures to be in color online only, authors should include the phrase <<color online>> in the figure captions. This is the author's responsibility. Authors will see these color figures when viewing their author page proofs on screen. Authors should always print their page proofs in black and white to see how they will appear in print. Authors will NOT be allowed to submit color figures to replace black and white figures in the page proof stage. To maximize the probability that figures will be published in color online and also print as good quality black and white or grayscale graphics, authors are encouraged to follow these figure submission guidelines: 1) Submit a color graphic in Tagged Image File Format (.tif); 2) Submit color graphics with a resolution of at least 300 dpi (600 dpi if there is text or line art in the figure); 3) Submit color graphics in CMYK format; 4) Submit figures sized to fit the actual column or page width of the journal so that reduction or enlargement is not necessary; 5) Submit multipart figures in one single electronic file.

Copyright © 2015, Materials Research Society. All rights reserved. No part of this publication may be reproduced, in any form or by any means, electronic, photocopying, or otherwise, without permission in writing from Cambridge University Press. Policies, request forms and contacts are available at: <http://www.cambridge.org/rights/permissions/permission.htm>. Permission to copy (for users in the USA) is available from Copyright Clearance Center <http://www.copyright.com>, email: info@copyright.com.

Journal of Materials Research Subscription Prices (2015)

[includes on-line web access]

	USA and Poss.	Non-US	Online Only
MRS Regular and Student Members	\$260.00	\$334.00	\$100.00
Institutions	\$1863.00	\$1863.00	\$1681.00

Journal of Materials Research (ISSN: 0884-2914) is published twenty-four times a year by Cambridge University Press, 32 Avenue of the Americas, New York, NY 10013 – 2473 for the Materials Research Society. Periodical Postage Paid in New York, NY and additional mailing offices. **POSTMASTER:** Send address changes to *Journal of Materials Research*, c/o Journals Dept., Cambridge University Press, 100 Brook Hill Drive, West Nyack, NY 10994-2113, USA.

Subscriptions, renewals, address changes, and single-copy orders should be addressed to Subscription Fulfillment, *Journal of Materials Research*, Cambridge University Press, 100 Brook Hill Drive, West Nyack, NY 10994-2133, USA (for USA, Canada, and Mexico); or Cambridge University Press, The Edinburgh Building, Shaftesbury Road, Cambridge, CB2 8RU, England (for UK and elsewhere). Allow at least six weeks advance notice. For address changes, please send both old and new addresses and, if possible, include a mailing label from a recent issue. Requests from subscribers for missing journal issues will be honored without charge only if received within six months of the issue's actual date of publication; otherwise, the issue may be purchased at the single-copy price.

Reprints of individual articles in *Journal of Materials Research* may be ordered. For information on reprints, please contact Cambridge University Press. Reprints of complete back issues older than the prior volume year may be ordered on an individual basis via the Cambridge Journals Online website. To determine availability, visit the appropriate page for the *JMR* back issue desired (www.journals.cambridge.org/jmr).

Individual member subscriptions are for personal use only.

Journal of MATERIALS RESEARCH

Editor-in-Chief: Gary L. Messing, *Ceramic materials, The Pennsylvania State University, USA*

Associate Editor, Adrian Mann, *Biomaterials, Rutgers University, USA*

Associate Editor, Jürgen Eckert, *Erich Schmid Institute of Materials Science, Austria*

Associate Editor, Linda S. Schadler, *Polymeric materials, Rensselaer Polytechnic Institute, USA*

2015 Principal Editors:

Lennart Bergström, *Materials processing, Colloidal science, Stockholm University, Sweden*

Edwin A. Chandross, *Organic materials, Materials Chemistry LLC, USA*

Xiaobo Chen, *Photocatalysis and batteries, University of Missouri-Kansas City, USA*

Yang-T. Cheng, *Mechanical behavior, Electrochemical energy storage, University of Kentucky, USA*

Paolo Colombo, *Pre-ceramic polymers, Porous ceramics, University of Padova, Italy; The Pennsylvania State University, USA*

Franz Faupel, *Functional nanomaterials, VPD, Metallic glasses, University of Kiel, Germany*

Amit Goyal, *Superconductors, Photovoltaics, 2D materials, Self-assembly, UT-Battelle/Oak Ridge National Laboratory, USA*

Andrea M. Hodge, *Nanostructured metals, Nanomechanics, PVD, University of Southern California, USA*

Himanshu Jain, *Inorganic glass, Optical, Electrical properties, Lehigh University, USA*

Suk-Joong L. Kang, *Sintering, Ceramics, Microstructure, Korean Advanced Institute of Science and Technology, Republic of Korea*

C. Robert Kao, *Metallic materials, Diffusion and joining, National Taiwan University, Taiwan*

Edson Roberto Leite, *Materials chemistry, Nanocrystals, Synthesis, Universidade Federal de São Carlos, Brazil*

Jörg Löffler, *Metallic materials/synthesis and properties, ETH Zurich, Switzerland*

Sanjay Mathur, *Oxide nanomaterials, Coatings, Nanotoxicity, University of Cologne, Germany*

Michael E. McHenry, *Magnetic materials, Carnegie Mellon University, USA*

Scott T. Misture, *In-situ diffraction, Electrochemically active ceramics, Alfred University, USA*

Paul Muralt, *Thin films, Piezoelectric and ferroelectric materials, Ecole Polytechnique Federale de Lausanne, Switzerland*

Akira Nakajima, *Photocatalysis, Surface wettability, Ceramic processing, Tokyo Institute of Technology, Japan*

Cewen Nan, *Ferroelectric, Multiferroic materials, Tsinghua University, China*

George M. Pharr, *Mechanical behavior, Nanoindentation, University of Tennessee, USA*

Ian M. Reaney, *Electroceramics, TEM, Thin films, The University of Sheffield, United Kingdom*

Joan M. Redwing, *Semiconductor thin films and nanowires, Processing, The Pennsylvania State University, USA*

Edward M. Sabolsky, *Electroceramics, Electrochemistry, Processing, West Virginia University, USA*

Winston Schoenfeld, *Optical materials, University of Central Florida, USA*

Don W. Shaw, *Epitaxy, Vapor deposition, Semiconductors, The University of Texas at Dallas, USA*

Susan B. Sinnott, *Computational materials science, The Pennsylvania State University, USA*

Eric A. Stach, *Materials characterization, Nanostructure growth, Brookhaven National Laboratory, USA*

Mauricio Terrones, *Nanocarbon, Graphene, 2-D metal chalcogenides, The Pennsylvania State University, USA; Shinshu University, Japan*

Terry M. Tritt, *Thermoelectrics, Clemson University, USA*

José Arana Varela, *Functional ceramics, Synthesis, Electro-optical, University of Sao Paulo State, Brazil*

William J. Weber, *Radiation effects, Nuclear ceramics, University of Tennessee; Oak Ridge National Laboratory, USA*

Tao Xie, *Polymers, Functional soft materials, Zhejiang University, China*

Sam Zhang, *Thin films/coatings, Nanyang Technological University, Singapore*

Yanchun Zhou, *Structural ceramics, Electronic structure, Aerospace Research Institute of Materials and Processing Technology, China*

Editorial Office: Ellen W. Kracht, *Publications Manager, Materials Research Society, Warrendale, PA*
Susan Seibel, *JMR Editorial Assistant, Materials Research Society, Warrendale, PA*
Kirby L. Morris, *JMR Production Assistant, Materials Research Society, Warrendale, PA*
Eileen M. Kiley, *Director of Communications, Materials Research Society, Warrendale, PA*

Cover: Figure 4(b) – AFM 3D image of a PTFE surface treated by He-O₂ plasma, showing increased hydrophobicity due to selective etching. [F. Reniers, J. Hubert, J. Mertens, T. Dufour, N. Vandencastele, V. Pascal, M. Raes, R. Lazzaroni, H. Terryn: Synthesis and texturization processes of (super)-hydrophobic fluorinated surfaces by atmospheric plasma. p. 3182].

Journal of MATERIALS RESEARCH

Volume 30, Number 21, November 13, 2015

INVITED FEATURE PAPERS

- 3153–3176 **Setting up a nanolab inside a transmission electron microscope for two-dimensional materials research** Yuting Shen, Litao Sun
- 3177–3191 **Synthesis and texturization processes of (super)-hydrophobic fluorinated surfaces by atmospheric plasma** J. Hubert, J. Mertens, T. Dufour, N. Vandecasteele, F. Reniers, P. Viville, R. Lazzaroni, M. Raes, H. Terryn

ARTICLES

- 3192–3200 **Nickel foam–graphene/MnO₂/PANI nanocomposite based electrode material for efficient supercapacitors** Muhammad Usman, Lujun Pan, Muhammad Asif, Zafar Mahmood
- 3201–3210 **Redox-responsive supramolecular polymer based on β -cyclodextrin and ferrocene-decorated main chain of PAA** Wenping Guo, Zhongli Lei
- 3211–3226 **Melting and crystallization of poly(3-hydroxybutyrate)/carbon black compounds. Effect of heating and cooling cycles on phase transition** Renate M.R. Wellen, Eduardo L. Canedo, Marcelo S. Rabello

INVITED FEATURE PAPER

- 3227–3240 **Kerfless exfoliated thin crystalline Si wafers with Al metallization layers for solar cells** Raphael Niepelt, Jan Hensen, Verena Steckenreiter, Rolf Brendel, Sarah Kajari-Schöder

ARTICLES

- 3241–3251 **Neodymium doped titania as photoanode and graphene oxide–CuS composite as counter electrode material in quantum dot solar cell** Laveena P. D'Souza, Sreeramareddygari Muralikrishna, Hunsur R. Chandan, Thippeswamy Ramakrishnappa, R. Geetha Balakrishna
- 3252–3258 **Exchange bias and training effect in NiCr₂O₄/Cr₂O₃ composite** Wang Liguang, Zhu Changming, Tian Zhaoming, Yuan Songliu
- 3259–3266 **Effect of transition metal ion doping on photocatalytic properties of In–Ti oxides** Mrinal Rajesh Pai, Atindra Mohan Banerjee, Shymala Rajkumar Bharadwaj
- 3267–3276 **Fracture toughness of nanocrystalline metal matrix composites reinforced by aligned carbon nanotubes** Shuhong Dong, Jianqiu Zhou, David Hui, Lu Wang
- 3277–3287 **Numerical approach to the evaluation of forming limit curves for zircaloy-4 sheet** Minsoo Kim, Felix Rickhey, Hyungyil Lee, Naksoo Kim
- 3288–3298 **Studies on microstructure and mechanical properties of keyhole mode Nd:YAG laser welded Inconel 625 and duplex stainless steel, SAF 2205** K. Devendranath Ramkumar, P. Shiva Goutham Kumar, V. Sai Radhakrishna, Karan Kothari, R. Sridhar, N. Arivazhagan, P. Kuppan
- 3299–3306 **Effects of distribution and growth orientation of precipitates on oxidation resistance of Cu–Cu₁₂–[Cr_{x/(12+x)}Ni_{12/(12+x)}]₅ alloys** Yuehong Zheng, Xiaona Li, Lujie Jin, Kun Zhang, Chuang Dong

(Continued)

- 3307–3315 **Multi-transformations in rapid solidification of highly undercooled hypoeutectic Ni–Ni₃B alloy melt** Junfeng Xu, Di Zhang, Feng Liu, Zengyun Jian
- 3316–3323 **Migration behavior of indium atoms in Cu/Sn–52In/Cu interconnects during electromigration** Mingliang Huang, Zhijie Zhang, Ning Zhao, Fan Yang
- 3324–3330 **Effect of cooling rates on solidification and microstructure of rapidly solidified Mg₅₇Zn₃₇Y₆ quasicrystal alloy** Min Xu, Xinying Teng, Jiwei Geng
- 3331–3342 **Effect of heat treatment on microstructure and mechanical properties of cast and directionally solidified high-Nb contained TiAl-based alloys** Shulin Dong, Ruirun Chen, Jingjie Guo, Hongsheng Ding, Yanqing Su, Hengzhi Fu
- 3343–3353 **In-situ study of microscale fracture of diffusion aluminide bond coats: Effect of platinum** Balila Nagamani Jaya, Sanjit Bhowmick, S.A. Syed Asif, Vikram Jayaram
- 3354–3362 **Mechanical properties and internal friction of Mg–Zn–Y alloys with a long-period stacking ordered structure at different Y/Zn atomic ratios** Jingfeng Wang, Zhongshan Wu, Ruopeng Lu, Yongliang Chen, Song Huang, Dezhao Qin, Wenxiang Yang, Fusheng Pan